

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	220	fill\$3 with nanotube and (array flat near2 panel)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:05
L2	207	L1 and (conductive substrate tantalum titanium carbide)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:05
L3	78	L2 and (coat\$4 deposit\$4) with (catalyst iron)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:06
L4	63	L3 and (hydrocarbon ethylene)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:07
L5	45	L4 and vacuum and ("H.sub.2" 'Ar')	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:07
L6	16	L2 and fill\$4 same (titanium tantalum vanadium)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:09
L7	26	conductive near2 fill\$3 with nanotube and (array flat near2 panel)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:10
L8	14	conductive near2 fill\$3 and nanotube	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/15 12:10
L9	47	fill\$3 with nanotube and (array flat near2 panel) and (vapor near5 growth)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/15 12:11
L10	18	gao.in. and nanotube and (array flat near2 panel)	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2005/03/15 12:11